

# Surface Characterization of Chemically Treated Aluminium Nitride Powders

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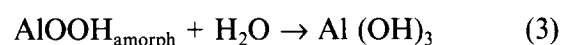
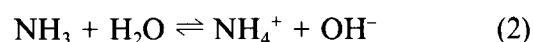
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## Abstract

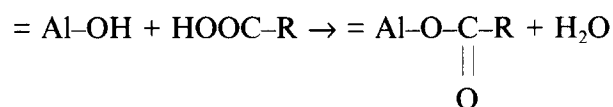
The surface characteristics of pure AlN powders are compared with those of so-called water stabilized powders. Both commercially available powders and stearic acid coated powders are used. By means of XPS, diffuse reflectance infrared spectroscopy and thermally programmed desorption mass spectrometry, information is obtained about the presence of surface groups. The behaviour of the different powders in aqueous suspension is compared by means of pH measurements and determination of the isoelectric points.

## 1 Introduction

The behaviour of powder suspensions is largely controlled by the surface chemistry of the solid. Also the sintering behaviour is influenced by the presence of physisorbed and chemisorbed surface groups. In nitride powders the surface oxygen content is also of particular importance for the sinterability. In case of AlN the oxygen content also influences the heat conductivity of the dense material. The chemical stability of AlN powders against oxidation and hydration is low and in water hydrolysis takes place. The reaction with water molecules is so fast that slip casting in aqueous suspensions is in fact not possible. For this reason some manufacturers produce AlN powders which have been treated chemically to increase the water resistance. Little is known about the surface chemistry of such AlN powders. Bowen *et al.*<sup>1</sup> showed the hydrolysis of uncoated AlN using diffuse reflectance infrared spectroscopy (DRIFT). A surface layer of stoichiometry close to AlOOH is formed, which gradually transforms into Al(OH)<sub>3</sub> according to the reactions:



This reaction is strongly dependent on pH and temperature.<sup>2</sup> Egashira *et al.*<sup>3,4</sup> suppressed the surface reactivity using carboxylic acid adsorption. They assume that surface hydroxyl groups play an important role during the adsorption, according to a reaction



To obtain more insight in the surface chemistry we have used different surface characterization techniques. In this paper we present results of characterization of pure and so-called water-resistant AlN powders.

## 2 Experimental

Table 1 gives a survey of the specifications of the powders used. Powders C and D (A100 and A200 from Advanced Refractories Technologies, ART, Buffalo, NY, USA) and E (Toyalnite WF from Toyo Aluminium K.K., Osaka, Japan) are commercially available water-resistant powders. AlN powder A (grade C from Starck, Berlin, Germany) was tested as-received and compared with the water resistant powders. Powders B were the Starck C powders coated by us according to the procedure described by Egashira *et al.*<sup>3</sup> Powder B1 was coated with stearic acid by refluxing in benzene, for powder B2 cyclohexane was used as a solvent. Further details are given in Ref. 5.

The reactivity in water was measured by following the change in pH for 0.05 wt% suspensions. To obtain a stable suspension of the powders C and D 1 wt% of the deflocculant Triton X100 (a polyoxyethylene alkylether) was added to these powders.

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Table 1. Specification of AlN powders

Sample No.	A	B1, B2	C	D	E
Origin	Starck Germany	Powder A coated with stearic acid	ART USA	—	Toyo Aluminium, Japan
	Grade C		A100	A200	Grade WF
FSSS, $\mu\text{m}$	1.2	as A	3–4	3–4	1.94
BET, $\text{m}^2/\text{g}$	3.7	as A	2.5–4	2.5–4	4.30
Al wt%	64.7	as A	66.05	66.0	—
N wt%	33.5	as A	33.0	32.7	32.9
O wt%	1.7	—	1.0	1.1	1.39
Si ppm	—	—	1000–2000	1000–2000	58
Water resistance (h)	—	6–12	2.5–4	—	> 72

To measure the  $\text{pH}_{\text{iep}}$  at the isoelectric point the powders were dispersed in water (again with Triton deflocculant in case of the powders C and D), containing 0.01 M  $\text{KNO}_3$  electrolyte. The suspensions were stabilized at  $\text{pH} = 2.5$  and titrated with 0.1 M KOH under vigorous stirring. The  $\text{pH}_{\text{iep}}$  was found from the zero crossing of the electroacoustic signal, using a Matec ESA analyser. For three powders XPS measurements were performed using a PHI Model 550 system and Al  $\text{K}\alpha$  radiation. On four powders diffuse reflectance infrared Fourier transform spectroscopy (DRIFT) was used. The region  $4000\text{--}800\text{ cm}^{-1}$  was scanned with  $4\text{ cm}^{-1}$  resolution, using 500 scans to improve the signal to noise ratio. Powders were diluted in KBr and measured against KBr as reference.

Finally we used thermally stimulated desorption (TPD) to obtain information about adsorbed species and their binding energies to the surface. Similar experiments for the characterization of  $\text{Si}_3\text{N}_4$  powders have been published earlier.<sup>6,7</sup> In the TPD equipment the sample is heated under high vacuum, while the desorbed gases are monitored by a mass spectrometer. A loosely pressed powder sample of about 20 mg is placed in a sample holder in the first vacuum chamber, which is pumped by a turbomolecular pump to  $10^{-7}$  mbar. After one night, the sample holder is transferred to the main vacuum chamber, which is pumped with an ion getter pump to a vacuum of  $< 5 \times 10^{-8}$  mbar. In this chamber the sample can be heated by means of an electron gun heater at a rate controlled by a PID controller. Presently the sample is surrounded by stainless steel radiation shields. This limits the maximum sample temperature to about  $900^\circ\text{C}$ , due to outgassing of the radiation shields. The desorbed gases are monitored by means of a quadrupole mass spectrometer (Balzers QMG511). Using the relative ionization cross sec-

tions for the different molecules, measured curves were corrected. No attempts were made to calculate ion concentrations.

### 3 Experimental Results

#### 3.1 XPS measurements

Results of the XPS measurements on pure and coated AlN powders are summarized in Table 2. The peaks at 77 and 400 eV are ascribed to Al and N respectively. The energies correspond to  $\text{Al}^{3+}$  and  $\text{N}^{3-}$ , and thus these peaks are due to bulk AlN. The carbon peaks at 288 eV are due to contamination; probably the same holds for the oxygen peak at 535 eV. Powder C shows silicon peaks at 105 and 180 eV. According to the supplier 1000–2000 ppm Si is present in these powders. Evidently this silicon is present in the surface coating. The carbon peak in this material is shifted over 0.7 eV; however, it is uncertain if this indicates the presence of organic carbon atoms. The spectra of powder E contain peaks at 199.2 and 149.2 eV

Table 2. XPS peaks for different AlN powders

Sample	Peak centre (eV)	Element
Starck Grade C (uncoated) powder A	76.7	Al
	400.0	N
	534.7	O
	287.8	C
ART A100 powder C	76.9	Al
	400.0	N
	534.7	O
	287.1	C
	105.0; 180.0	Si
Toyalnite powder E	77.4	Al
	119.02; 149.2	P (from phosphate)
	400.3	N
	535.6	O
	287.8	C

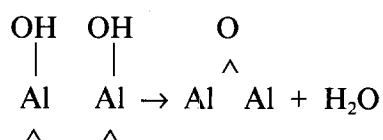
which are assigned to P in phosphate groups. The shift of the oxygen peak with 0.9 eV may also be due to the bonding in the phosphate group. The presence of phosphate is in accordance with a remark in Ref. 8.

### 3.2 DRIFT spectra

All powders show about 8 strong bands between 600 and 1400  $\text{cm}^{-1}$  which can be assigned to lattice phonons of AlN.<sup>9</sup> A weak band at 1973  $\text{cm}^{-1}$  in powder E agrees well with the  $3\text{TO}_1$  mode found in Ref. 9. Broad IR bands at 1600  $\text{cm}^{-1}$  and around 3400  $\text{cm}^{-1}$  are due to weakly bonded water molecules. Powders B clearly show the  $\text{CH}_2$  stretching bands around 2800  $\text{cm}^{-1}$ , originating from the stearic acid coating. The spectra of the powders C and D show two extra peaks which could not be assigned unambiguously. For instance a peak at 2160  $\text{cm}^{-1}$ , present in both C and D may be assigned to a metal-hydrogen band. Ref. 10 attributes this band on pure AlN to Al-H stretching, although the authors note that the frequency is rather high in comparison with AlH in aluminium hydrides. However, the same frequency is observed for Si-H on  $\text{Si}_3\text{N}_4$  powders.<sup>11</sup> The band is not present in the uncoated powder, and since XPS shows the presence of Si on the surface of powder C this suggests that it is due to an SiH vibration. However, the absorption is also present in powder E, where no Si was found with XPS. A broad band in both powders at 3200  $\text{cm}^{-1}$  may be due to  $\text{NH}$ ,<sup>9</sup> while a sharper peak at 2965  $\text{cm}^{-1}$  may indicate the presence of carbon. These assignments remain uncertain, however.

### 3.3 Temperature programmed desorption

TPD spectra of the different powders are shown in Figs 1–5. All powders show a high desorption peak of water at about 100°C. This is clearly physisorbed water. However, the water desorption continues up to about 600°C. By analogy with the reaction of silanol groups on silicon nitride, this may be due to the surface reaction



After coating with stearic acid (powders B) the physisorbed water peak has a much lower intensity. As could be expected, the stearic acid coated material shows many peaks due to decomposition products of the organic coating, e.g.  $\text{C}_6\text{H}_{11}$ ,  $\text{C}_6\text{H}_7$ ,  $\text{C}_6\text{H}_5$ ,  $\text{C}_4\text{H}_9$ ,  $\text{C}_4\text{H}_7$ ,  $\text{C}_3\text{H}_7$ ,  $\text{C}_3\text{H}_5$ ,  $\text{C}_2\text{H}_5$ , and lower masses. Figure 2 shows two of these peaks, at mass 41 and 55 respectively. The hydrocarbons show a desorption maximum at about 400°C,

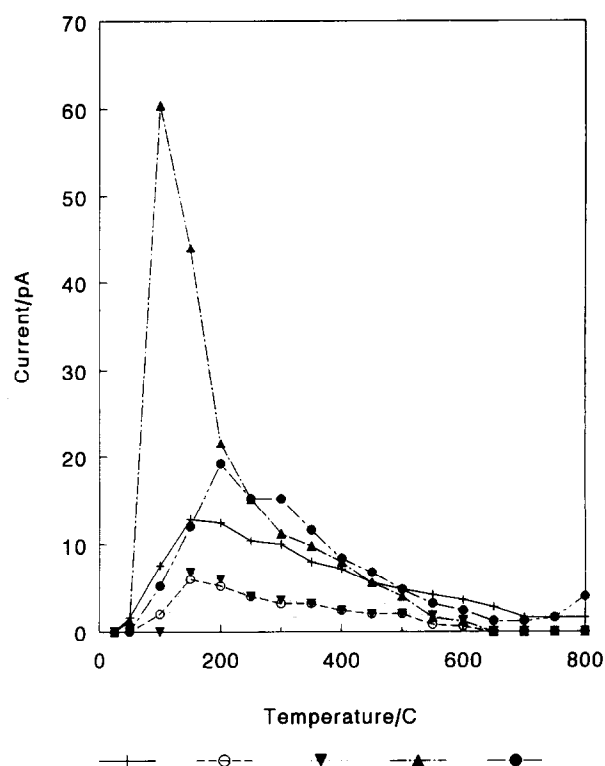


Fig. 1. TPD mass spectrum of uncoated AlN (powder A). Legends from left to right + M = 2,  $\text{H}_2$ ;  $\circ$  M = 16 and  $\blacktriangledown$  M = 17 overlapping peaks  $\text{NH}_2$ ,  $\text{NH}_3$ ;  $\blacktriangle$  M = 18,  $\text{H}_2\text{O}$ ;  $\bullet$  M = 28,  $\text{N}_2$ .

indicating that the coating is chemically bonded to the AlN surface. No difference was observed between the powders coated from stearic-acid benzene or stearic-acid cyclohexane solutions.

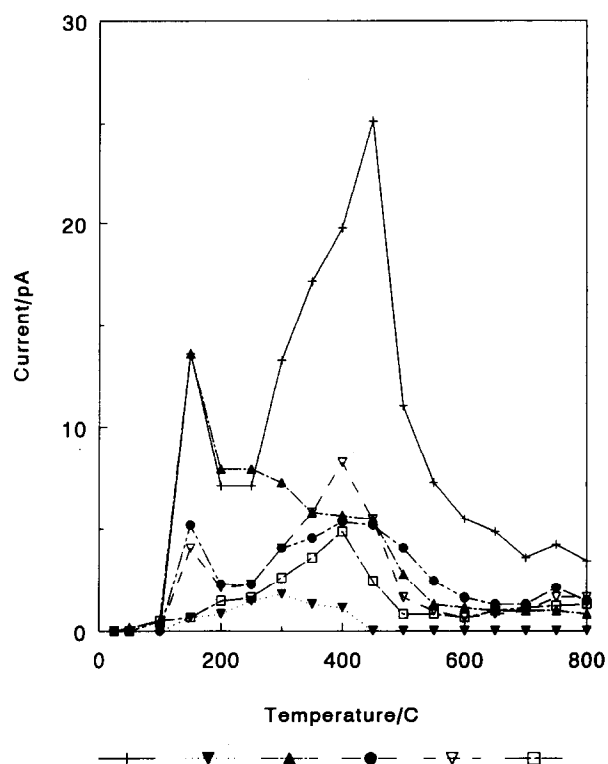


Fig. 2. TPD mass spectrum of stearic acid coated AlN (powder B). Legends from left to right + M = 2,  $\text{H}_2$ ;  $\blacktriangledown$  M = 17,  $\text{NH}_3$ ;  $\blacktriangle$  M = 18,  $\text{H}_2\text{O}$ ;  $\bullet$  M = 28,  $\text{N}_2$ ;  $\nabla$  M = 41,  $\text{C}_3\text{H}_5$ ;  $\square$  M = 55,  $\text{C}_4\text{H}_7$ .

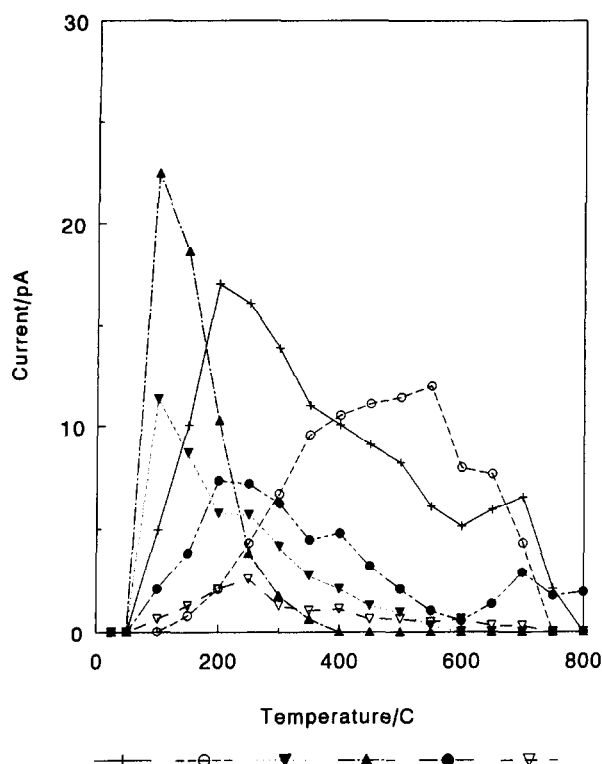


Fig. 3 TPD mass spectrum of water resistant AlN (powder C). Legends from left to right + M = 2, H<sub>2</sub>; ○ M = 16, NH<sub>2</sub>; ▼ M = 17, OH; ▲ M = 18, H<sub>2</sub>O; ● M = 28, N<sub>2</sub>; ▽ M = 41, C<sub>3</sub>H<sub>5</sub>.

Powder C shows a peak at mass 41, which may be due to hydrocarbon (note that in blank runs hydrocarbons have never been found, due to the

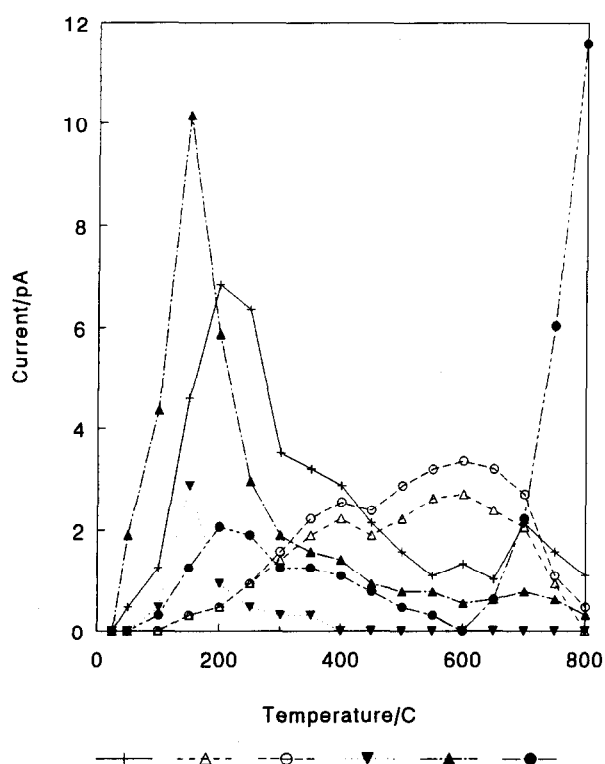


Fig. 4. TPD mass spectrum of water resistant AlN (powder D). Legends from left to right + M = 2, H<sub>2</sub>; Δ M = 15, NH; ○ M = 16, NH<sub>2</sub>; ▼ M = 17, OH; ▲ M = 18, H<sub>2</sub>O; ● M = 28, N<sub>2</sub>.

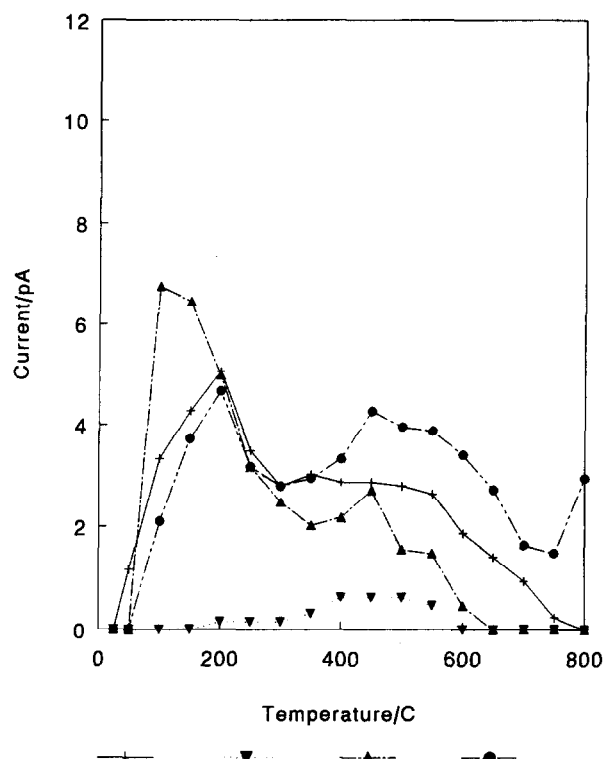


Fig. 5. TPD mass spectrum of water resistant AlN (powder E). Legends from left to right + M = 2, H<sub>2</sub>; ▼ M = 16 and 17 overlapping peaks NH<sub>2</sub>, NH<sub>3</sub>; ▲ M = 18, H<sub>2</sub>O; ● M = 28, N<sub>2</sub>.

clean vacuum system). The TPD spectrum of D shows a strong peak at mass 28 above 700°C, which is not observed in the other powders. This may be due to Si instead of N<sub>2</sub>, as shown by the XPS and suggested by the DRIFT spectra, however, the fact that it is not observed with powder C contradicts this. Powders A, C, D and E all show desorption of NH<sub>3</sub> at about 150°C, indicating a weak bonding. As mentioned above, AlN reacts with water to form AlOOH and NH<sub>3</sub>. Part of the ammonia formed by reaction of AlN with water vapour will remain adsorbed at the surface and may cause the low temperature desorption peak.

In all powders we find desorption of H<sub>2</sub> and N<sub>2</sub>. The peaks are closely correlated and show maxima at 200 and about 400°C. A similar behaviour was found in Si<sub>3</sub>N<sub>4</sub> powders.<sup>7</sup> In silicon nitride there is ample evidence for the presence of OH and NH surface groups.<sup>13,14</sup> Therefore we assume that the desorption of hydrogen and nitrogen from the AlN powders is also due to the presence of NH groups at surface sites. Powders C, D and to a lesser extent E all show a peak at about 500–600°C for mass 15 and 16. These peaks are also closely correlated and are therefore attributed to NH and NH<sub>2</sub>. Desorption of powder E is low over the whole temperature range. No hydrocarbon peaks were detected for this powder. In view of the XPS results this may indicate a coating with phosphate without organic groups.

Milling of the uncoated AlN powder for 70 h in dry propanol gives a TPD spectrum identical with that of the untreated powder, i.e. the adsorbed species are not removed by this treatment. It also shows that AlN is quite stable in propanol, in agreement with the observation in Ref. 1.

We have also measured the TPD spectrum of uncoated Starck powder after heat treatment at 1000°C in nitrogen. Most of the H<sub>2</sub>, N<sub>2</sub>, and H<sub>2</sub>O are removed, while the NH<sub>3</sub> and NH<sub>2</sub> peaks disappear almost completely.<sup>12</sup> A similar observation was made for silicon nitride powders.<sup>7</sup>

### 3.4 Electroacoustic measurements

The stability of the powders was measured by following the pH of aqueous suspensions at room temperature. Figure 6 shows the change in pH for 0.5 wt% suspensions of five different powders. The uncoated powder A starts to react from the very beginning. The end value for these dilute suspensions is about pH 11. As shown earlier the addition of Triton surfactant does not influence these results.<sup>5</sup> The figure shows that both the stearic acid coated powder B and powder E are stable for long times at room temperature. This confirms earlier results of Egashira *et al.*<sup>3</sup> No difference was observed between B1 and B2. Powders C and D are stable up to about 30 h, as specified by the supplier. One may suspect that the stability depends on the starting pH of the dispersions. Therefore we repeated the experiment with powder E, the most stable powder, using different ini-

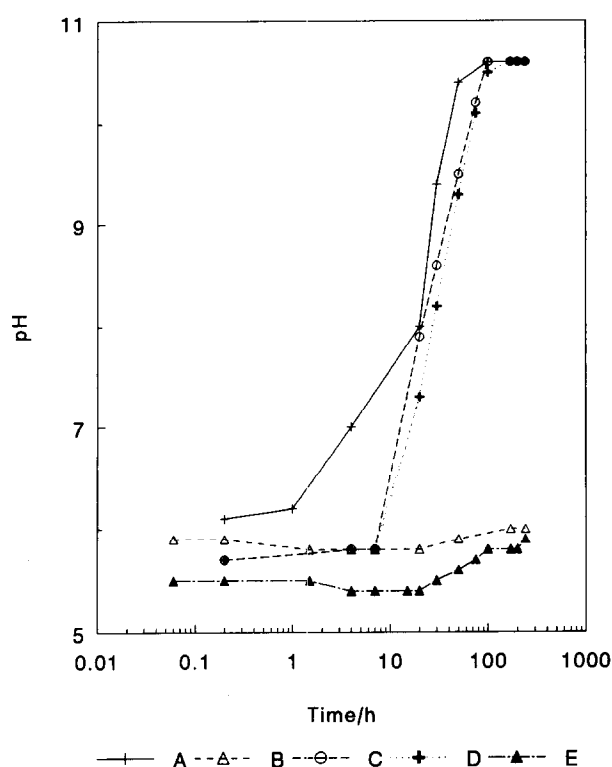


Fig. 6. Time dependence of pH of 0.05 wt% dispersions of AlN (powders A-E) in water.

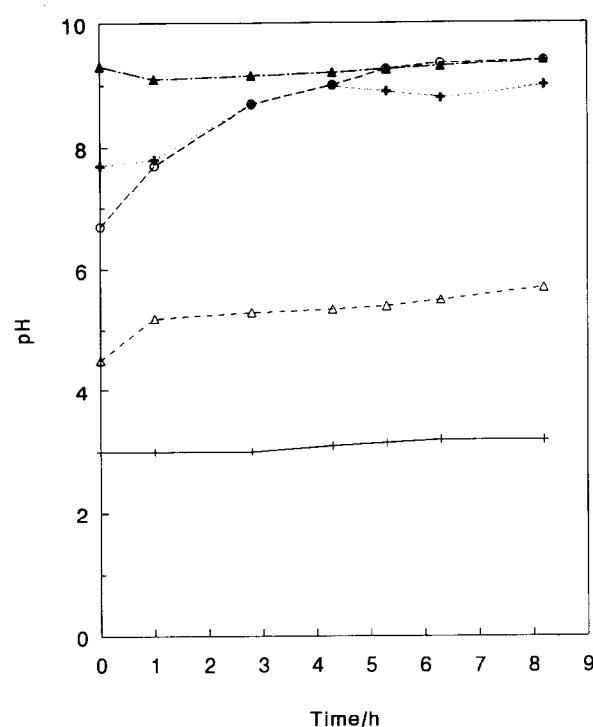


Fig. 7. Stability of powder E in water with different starting pH.

tial pH values. Figure 7 shows the results. Suspensions of powder E show a decrease in stability at high pH values. For slip casting one uses much higher solid loadings. Therefore we followed the pH of 30 vol% (58 wt%) suspensions as a function of time (Fig. 8). The decomposition rate is considerably enhanced and hydrolysis of the uncoated

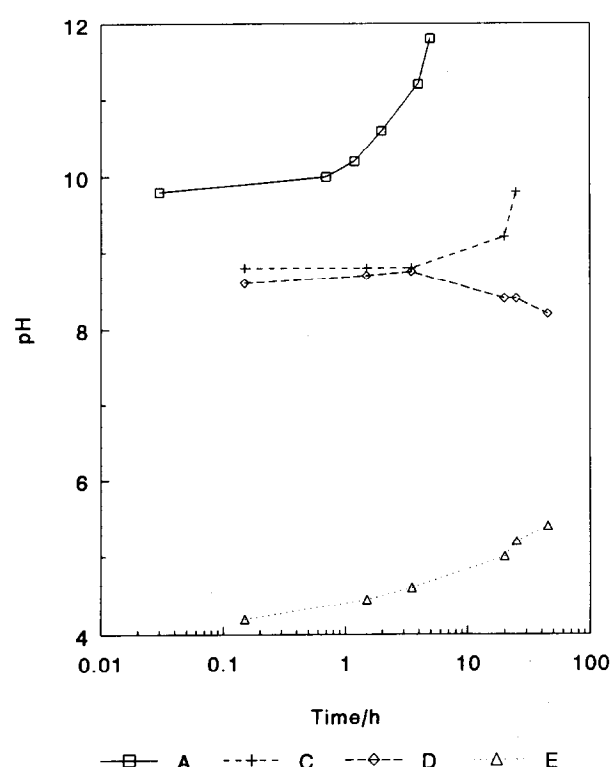
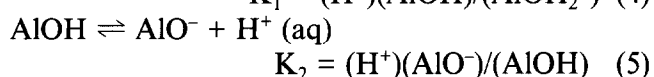
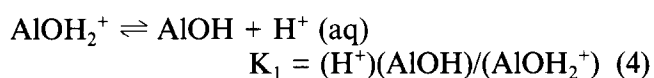


Fig. 8. Time dependence of pH of 30 vol% slips of AlN powders in water.

**Table 3.** Isoelectric point for suspensions with different solid contents

Sample	Conc. wt%	pH <sub>iep</sub>
Starck Grade C (powder A)	4	9.7
	10	8.9
	25	8.8
	50	8.8
ART A100 (powder C)	4	8.5
	10	8.5
	25	8.4
	50	8.1
ART A200 (powder D)	4	7.9
	10	7.8
	25	7.7
	50	7.5
Toyalnite (powder E)	4	6.0
	10	6.0
	25	6.0
	50	5.8

powder is visible within 1 h. For powder B the reaction starts between 24 and 48 h. Due to the exothermal nature of the reaction the rate rapidly increases and the slip even became a solid mass. Note that although suspensions are made with water of pH = 7, the pH at the first measuring point after 2 min has changed considerably. Suspensions of powder E become acidic, powders C and D slightly basic. Results of the determination of the isoelectric point by means of ESA measurements are shown in Table 3. Measurements were performed for four different concentrations of the suspensions, *viz.* 4, 10, 25 and 50 wt% AlN in water. There is a slight tendency towards decreasing pH<sub>iep</sub> values for increasing concentrations. The surface charge is positive below the isoelectric point and negative above. The pH<sub>iep</sub> value of 8.9 for the uncoated powder is in close agreement with the value of 9.0 found by Seitz *et al.*<sup>15</sup> From a comparison with alumina these authors concluded that Al<sub>2</sub>O<sub>3</sub> and AlN exhibit a similar surface. This would mean that the surface contains amphoteric AlOH groups, which may be ionized in solution according to the following reactions:



The point of zero charge (pzc) is found when (AlOH<sub>2</sub><sup>+</sup>) = (AlO<sup>-</sup>). From eqns 4 and 5 it follows that this is the case when pH<sub>pzc</sub> = (pK<sub>1</sub> + pK<sub>2</sub>)/2. Assuming pH<sub>iep</sub> = pH<sub>pzc</sub> we find pK<sub>1</sub> + pK<sub>2</sub> = 17.8. One also finds the ratio of basic to acid sites as a function of pH:

$$\log(\text{AlOH}_2^+)/(\text{AlO}^-) = \text{pK}_1 + \text{pK}_2 - 2\text{pH} = 17.8 - 2\text{pH} \quad (6)$$

Powder E has a pH<sub>iep</sub> of 6.0, which indicates the

presence of acidic surface groups. This is in accordance with the observation of phosphate groups in the XPS and IR spectra. The behaviour of powder D indicates that the organosilicon coating results in a pH<sub>iep</sub> of about 7.5. The pH<sub>iep</sub> of powder C is in between the value of uncoated powder A and powder D, suggesting that the surface is incompletely covered. The higher water sensitivity of C compared to D points in the same direction. Both powders were poorly dispersible in water which is related to the hydrophobic coating.

#### 4 Summary and Conclusions

The surface of coated and uncoated AlN powder has been investigated by means of XPS, DRIFT spectroscopy, TPD and electrokinetic measurements. Uncoated AlN has a surface similar to alumina with amphoteric AlOH groups. The stability of AlN in water increases in the sequence pure AlN < ART coated < stearic acid coated < Toyalnite coated. The surface of ART powder C seems to be only partially covered by a coating containing both silicon and organic carbon. Stearic acid gives a better protection, but a considerable quantity of this organic compound is present on the surface, which has to be removed before sintering. The Toyalnite powder contains phosphate groups. Due to the coatings the isoelectric point shifts from pH 9 for pure AlN via 7.5 for ART powder to 5.8 for the Toyalnite powder.

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